Specification

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Introduction

X series is a professional deal with all kinds of advanced chip performance test, comprehensive and efficient semi-automatic wafer prober, integrates the electrical, light wave, microwave, etc, to 60 $^\circ\text{C} \sim 300 \ ^\circ\text{C}$ high temperature KuanQu and testing precision, can match various test application environment, at the same time super efficient well test run of the system speed > 70 mm/s, effectively improve testing efficiency by more than 40%, for all kinds of wafers and provide excellent reliability test device.



Application Direction

All kinds of devices and Wafer, etc., conduct characteristic analysis of I-V, C-V, optical signal, RF, 1/ F noise, RF test, high-power Wafer test, etc

Product Feature

- Super efficient and excellent test running speed >70mm/s, test efficiency increased by more than 40%
- Advanced 3 times patented optical microscopy system, high precision measurement and dynamic monitoring, more convenient operation of the point needle
- -60°C~300°C ultra-high temperature wide area
- Software automation test, precise calibration of mechanical accuracy
- Integrated control system, instrument fast and convenient access test
- Excellent test accuracy, operating efficiency and system stability
- Support automatic expansion and upgrade

	Model	SX-6	SX-8	SX-12	
Microscope X-Y-Z	X-Y Travel range	2"* 2"			
	X-Y Resolution	0.1µm			
	X-Y Repeatability	±2µm			
	X-Y Move speed	≥10mm/sec			
	Z Travel range	5"			
	Z Resolution		0.1µm		
	Z Repeatability	≤ ±1µm			
	Z Move speed	≥10mm/sec			
Microscope	Variable	Zoom:15: 1,Three gears and could display low(0.6X) and high(2.5X or 9X)			
	magnification microscope		magnification in the same time)	
	Camera	Double cameras (200W or 500W Industrial digital camera)			
Micropositioner Specification	Mechanical resolution	10µm / 2µm / 0.7µm			
	X-Y-Z Move range	13mm-13mm			
	Current leakage	10pA / 100fA / 10fA			
	Connector type	Banana plug adapter/Coaxial /Three-axis/ SMA /SHV etc.			
	Base	Magnetic/vacuum adsorption base			
	Temperature range	- 60°C-200°C (Standard), other Temperature range upon request			
	Temperature stability	±0.1℃			
	Tmeperature resolution	0.01°C			
Temperature specification	Heating	- 60°C to +25°C ≤ 10min			
	time(12"chuck)	+25°C to +200°C ≤10 min			
	Cooling		+ 200°C to +25°C ≤ 12min		
	time(12"chuck)	+ 25°C to -60°C ≤ 25min			
	Noise	<60dB			
	Heating method	Low Voltage DC(LVDC)/PID control		rol	
	Refrigeration method	Refrigeration compressor			
Anti-Vibration	Anti-Vibration	Air film anti-vibration system, Ensure nonvisible vibration in the screen			
	method	when the microscope zooming in at 2000X			
Anti-vibration	Vibration	In the process of chuck movement, it can be extremely fast to ensure the		ely fast to ensure the	
	suppression	stability of the chuck ≤1S, Improve the test efficiency.		t efficiency.	
system mask	EMI shielding	> 20 dB (typical) @ 1 kHz to 20GHz		Hz	
	Light attenuation	≥ 120 dB			
	Spectral noise floor	≤ -150 dBVrms/rtHz			
	System AC noise	≤15 mVp-p (≤ 1 GHz)			
		Software func	tion		
Automatic wafer alignment			Automatic wafer height measur	ement and compensation	
Automatic Die size measurement and auto mapping			Support Z, N shape test		
Wafer map edit arbitrary			One touch automatic RF calibrate and probe tips cleaning		
Demarcate difference data with lnk mark			Separation of OS and application independently.	on software, can be upgraded	
Real-time test results display			Robust data storage and processing capabilities		
Easy data management of the instrument input/output			Automatic data and curves stor	rage and remote access	
The test results can be divided into different bin values			Communication interface: R23	2/485/TCP/IP/GPIB	

Multi tester fast integration , support both single Die testing and

continuous testing

Model		SX-6	SX-8	SX-12		
Dimension (W*L*H)		1000mm * 1400mm * 1400mm	1100mm * 1500mm * 1400mm	1200mm * 1600mm * 1400mm		
Weight(about)		1000KG	1150KG	1350KG		
Electricity Demand		AC220V, 50~60Hz				
CDA demand		0.4~0.8Mpa				
Chuck	Size	6"	8"	12"		
	X-Y Travel range	200mm * 300mm	250mm * 400mm	350mm * 500mm		
	X-Y Resolution	0.1μm				
	X-Y Repeatability	≤±1µm				
	X-Y Move speed	≥70mm/sec				
	Z Travel range	20mm				
	Z Resolution	0.1μm				
	Z Repeatability	≤±1µm				
	Z Move speed	≥20mm/sec				
	Theta Travel range	±10°	Theta resolution	0.0001°		
	Sample Fixed mode	Vacuum adsorption , Independent control				
	Sample Exchange	Chuck quickly roll out for wafer fast exchange.				
	Structure	Triaxial ultra-low noise design, Gold plating, Chuck surface is electrical floating				
Platen	Specifications	O shape platen, 12 micropositioners available (When the octagon box is not installed)				

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